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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
U.S. Designated/Elected Office (DO/EO/US)

In re Application of:

Yoshitake NATSUME et al.

Examiner: Sample, D.

Serial No.: 10/501,996

Art Unit: 1755

Filing Date: July 21, 2004

For: SINTERED OBJECT OF SILICON MONOXIDE AND METHOD OF
PRODUCTION THEREOF

AMENDMENT

Commissioner of Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated December 6, 2005, please amend the
subject application as follows: